Express Mail No.: ET318110530

Date of Deposit: August 2, 2002

Atto Docket No.: 19546-024 16/E

AUG 0 2 2012

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

RADENA pplicants:

R. Buckley

For:

SLIP-RESISTANT HORIZONTAL SEMICONDUCTOR WAFER BOAT

Filed:

June 6, 2000

Serial No.:

09/588,396

Examiner:

K. Tran

Group Art Unit:

3634

RECEIVED

AUG 0 7 2002

Boston, MA August 2, 2002 GROUP 3600

Commissioner for Patents Washington, D.C. 20231

AMENDMENT AND RESPONSE UNDER 37 C.F.R. §1.111

Sir:

This reply is made in response to the Office Action dated May 7, 2002. This Response is due on or before August 7, 2002. Kindly enter the following amendments and remarks in response to the Office Action. Reconsideration and withdrawal of the rejections are respectfully requested.

In the specification:

Please replace the paragraph beginning at page 10, line 18 and extending to page 11, line 18, with the following rewritten paragraph:

developed. FIGS. 2 and 3 are schematic representations of one embodiment of the wafer boat 30 in accordance with the present invention, as viewed from different angles. In particular, unlike current wafer boats which provide support for each wafer at four points (two lower points to support the weight of the wafer, and two upper points to maintain the wafer in the vertical orientation as illustrated in FIG. 1), the wafer boat of the present invention is provided with two upper support guides 36a, 36b to maintain the wafer 32 in the vertical orientation, and a single lower supporting grooved portion 38 to support the weight of the wafer 32. Once the material of which wafer boat 30 is fabricated is selected, the supporting grooved portion 38 which is in a plane lower than the upper